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# INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Application Number		10517575
Filing Date		2004-12-09
First Named Inventor	Victo	r Lu
Art Unit		2813
Examiner Name	Moni	ica D. Harrison
Attorney Docket Numb	oer	H0004019.68746 US - 4780

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Examiner Initial*	Cite No	Patent Number	Kind Code <sup>1</sup>	Issue Date	Name of Patentee or Applicant of cited Document	Pages,Columns,Lines where Relevant Passages or Relevant Figures Appear
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	2	4299938		1981-11-10	Ciba-Geigy Corporation	
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## INFORMATION DISCLOSURE STATEMENT BY APPLICANT

( Not for submission under 37 CFR 1.99)

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Examiner Initial*	Cite No	Publication Number	Kind Code <sup>1</sup>	Publica Date	tion	Name of Pate of cited Docu	entee or Applicant ment	Relev	s,Columns,Lines where ant Passages or Releve es Appear	
	1	20060110682	A1	2006-05	-25	Shipley Compa	any, L.L.C.	The same and the s		
	2	20060155594	A1	2006-07	·-13	Jess Almeida,	et al.			на в в в в в в в в в в в в в в в в в в в
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Application Number	1	0517575
Filing Date	2	2004-12-09
First Named Inventor	Victor L	.u
Art Unit	2	2813
Examiner Name	Monica	D. Harrison
Attorney Docket Numb	er l	-10004019.68746 US - 4780

			Application Number		10517575	
			Filing Date		2004-12-09	_
		TION DISCLOSURE	First Named Inventor	Vict	or Lu	_
		NT BY APPLICANT	Art Unit		2813	
Not for s	submi	ssion under 37 CFR 1.99)	Examiner Name	Mor	nica D. Harrison	
			Attorney Docket Num	ber	H0004019.68746 US - 4780	
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	Application Number		10	0517575	
	Filing Date		20	004-12-09	
INFORMATION DISCLOSURE	First Named Inventor	Victo	or Lu	1	www.
STATEMENT BY APPLICANT (Not for submission under 37 CFR 1.99)	Art Unit		2	813	
( NOT 101 SUDMISSION WINES 37 OF 17 1:33)	Examiner Name	Mon	ica l	D. Harrison	
	Attorney Docket Number			10004019.68746 US - 4	1780
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Examiner Signature				Date Considered	VII.A L
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